



## Effect of the thickness of the MoO<sub>3</sub> layers on optical properties of MoO<sub>3</sub>/Ag/MoO<sub>3</sub> multilayer structures

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The electrical and optical properties of MoO<sub>3</sub>/Ag/MoO<sub>3</sub> multilayer structures have been studied using the Ag deposition rate and layer thicknesses as parameters. When the silver film is deposited at 0.20 nm/s rate, the silver layer thickness necessary to achieve the percolation threshold of the resistivity  $\rho$  towards conductive structures is 10 nm. Below 10 nm, the films are semiconductor and above the films are conductors. In the present work, the variation of the thicknesses of top and bottom MoO<sub>3</sub> layers is shown to strongly modify the optical properties of the multilayer structures. By using a Ag thickness of 10 nm, we demonstrate an increasing of the transmittance of the MoO<sub>3</sub>/Ag/MoO<sub>3</sub> structures by optimizing the MoO<sub>3</sub> layers thicknesses. When the MoO<sub>3</sub> bottom layer is 20 nm thick, and the MoO<sub>3</sub> top layer is 35 nm, the maximum transmission is 86% at the wavelength of 465 nm, while the averaged transmission in the visible range (350 nm–800 nm) is 70%. The best measured conductivity,  $\sigma = 1.1 \times 10^5 (\Omega \text{ cm})^{-1}$ , corresponds also to this MoO<sub>3</sub> (20 nm)/Ag (10 nm)/MoO<sub>3</sub> (35 nm) structure. A good qualitative agreement between the theoretical calculations of the variation of the optical transmittance and reflectance of the MoO<sub>3</sub>/Ag/MoO<sub>3</sub> structures is also highlighted.

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